**CLAIMS** 

1. A semiconductor device comprising at least one transistor formed on a surface of III-V Compound single crystal substrate,

wherein said III-V Compound single crystal substrate has a distribution of lattice constant which satisfies the following:

$$D/d_o \le 4 \times 10^{-5}$$

whereby D is defined as the value of difference between the maximum and minimum values of lattice constant within the surface of said III-V single crystal substrate in a region the size of said III-V single crystal substrate, and do is defined as the lattice constant at room temperature of III-V single crystal having the theoretical composition of III-V Compound single crystal.

- 2. A semiconductor device according to claim 1, wherein the theoretical composition is the stoichiometric composition.
- 3. A semiconductor device according to claim 1, wherein said at least one transistor is at least one field effect transistor.
- 4. A semiconductor device according to claim 3, wherein said at least one field effect transistor is a MESFET,

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